

Ultra-Small-Angle X-ray Scattering on Nano-Particle Monolayers



Hendrik K. Kammler^{1,2}, Gregory Beaucage², Sotiris E. Pratsinis¹ ¹ Particle Technology Laboratory, ETH Zürich, CH-8092 Zürich, Switzerland; http://www.ptl.ethz.ch ² Department of Material Science and Engineering, University of Cincinnati, Cincinnati, OH-45221-0012, USA

Introduction

Monolayers of silica nanoparticles were collected on metal substrate from a flame aerosol reactor by thermophoretic sampling (TS). The third generation synchrotron source coupled with ultra-small-angle xray scattering (USAXS) camera at APS (UNICAT) was capable of measuring a reasonable scattering pattern on such thermophoretically collected samples. This new TS-USAXS technique enables monolayer-like particle deposition. It further allows the collection of localized samples for USAXS analysis, thus, enabling point wise mapping of flame reactors. Data along certain streamlines or 3-D mapping is possible.

Local particle samples with extremely narrow size distributions were found indicating a much higher degree of uniformity in particle size than previously expected from powders samples on similar aerosol

Growth of Nanoparticles

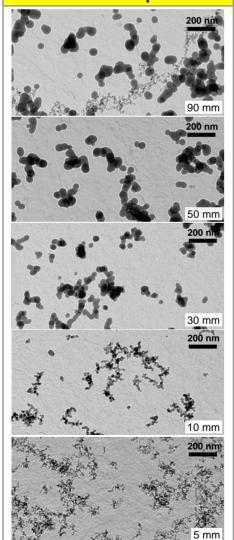
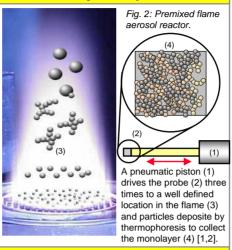


Fig. 1: Silica particles as collected by conventional thermophoretic sampling (TS) [1,2]. The growth of particles can be visualized. Using aluminum foil instead of TEM grids and performing multiple sampling from the same location in the flame, the Al-probe was covered with a silica monolayer [1] (as indicated in Fig. 2).

Monolayer Deposition



Scattering of Monolayers

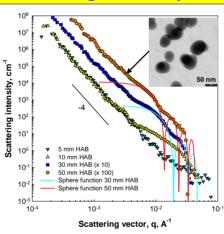


Fig. 3: At 5 mm height above burner (HAB), scattering from small particles is detected. At 10 mm HAB, which corresponds to 2 ms of particle residence time in the flame, grown particles are detected. With increasing HAB, particles grow even larger into spheres with low polydispersity. Spectra at 30 and 50 mm HAB can be described well with the sphere function (solid lines)[3]:

$$I(q) = A \cdot \left(3 \cdot \frac{\sin(q \cdot R) - (q \cdot R) \cdot \cos(q \cdot R)}{(q \cdot R)^3} \right)^{\frac{1}{2}}$$

The slope of -4 at low q values is probably from the Al-foil used for particle deposition. The same samples were measured as well at ESRF in Grenoble, France, and showed identical scattering patterns.

References

- [1] Dobbins, Megaridis, Langmuir 3, 254 (1987).
- [2] Kammler, Beaucage, Kohls, Agashe, Ilavsky, J. Appl. Phys. (2004) submitted.
- Guinier, Fournet, Small Angle Scattering of X-rays, Wiley, New York (1955).
- a) Beaucage, J. Appl. Crystallogr. 28, 717 (1995), b) Beaucage, J. Appl. Crystallogr. 29, 134 (1996),
- Kammler, Beaucage, Mueller, Pratsinis, Langmuir 20, 1915 (2004).

Monitoring growth dynamics

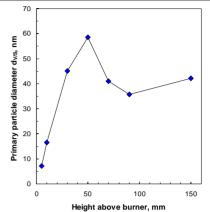


Fig. 4: The primary particle size, d_{V/S}, obtained by USAXS evaluation [4,5] increases up to 50 mm height above the burner (HAB) as particles collide and coagulate/coalesce at high temperature. At the flame edge, small particles are formed since temperature is significantly lower [2]. Above 50 mm HAB, flame turbulence brings large agglomerates with these small primary particles to the flame center, decreasing the average primary particle diameter [2],

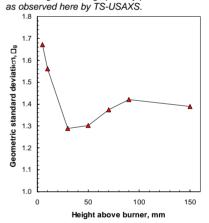


Fig. 5: σ_{a} , goes through a minimum indicating narrow size distributiutions of $\sigma_{\rm g}$ < 1.3 (at 30 and 50 mm HAB), which is well below the self-preserving limit of 1.45 for coagulation. This corresponds well with Fig. 4.

Conclusions

- Good scattering patterns were obtained from silica nanoparticle monolayers by ultra-small-angle x-ray scattering
- Along particle formation, regions of low polydispersity were idintifird by this new scampling technique. The sphere function described these narrow scattering pattern with high accuracy

Acknowledgements

The authors thank Dr. J. Ilavsky and Dr. P. Jemian for the UNICAT beamline (33ID) at APS support and Dr. S. Tsantilis for the modeling. Financial support by U. S. National Science Foundation (CTS-0070214), Swiss National Science Foundation (200021-101901/1) is acknowledged. The UNICAT facility at the Advanced Photon Source (APS) is supported by the U.S. DOE under Award No. DEFG02-91ER45439, through the Frederick Seitz Materials Research Laboratory at the University of Illinois at Urbana-Champaign, the Oak Ridge National Laboratory (U.S. DOE contract DE-AC05-00 of Standards and Technology (U.S. Department of Commerce) and UOP LLC. The APS is supported by the U.S. DOE, Basic Energy Sciences, Office of Science under contract No. W-31-109-ENG-38.